



Electrochemical Technology for New Materials Synthesis and Reprocessing

Guest Editor:

Prof. Dr. Yury Zaikov

Institute of High-Temperature
Electrochemistry, Ural Branch,
Russian Academy of Sciences,
620066 Ekaterinburg, Russia

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Message from the Guest Editor

Dear Colleagues,

The development of new technologies, materials, and electrochemical devices requires a deep understanding of the thermodynamics and kinetics of processes at the electrode boundary. Therefore, the Special Issue of «Electrochemical Technology for New Materials Synthesis and Reprocessing» is devoted to the following topics:

- Modeling of properties and structures of molten media and electrochemical devices;
- Kinetics and thermodynamics of electrode processes on solid and molten electrodes in molten salts;
- Materials for the aerospace industry and nuclear energy;
- New electrochemical and pyrochemical technologies;
- Production of metals and alloys by electrolysis of fluoride, chloride, and oxide melts;
- Promising functional materials for new-generation solid-oxide electrochemical devices.





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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

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Processes Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland

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